



Docket No.: 3811-0130P  
(PATENT)

**IN THE UNITED STATES PATENT AND TRADEMARK OFFICE**

In re Patent Application of:  
Yi LYU et al.

Application No.: 10/695,777

Confirmation No.: 6882

Filed: October 30, 2003

Art Unit: 1712

For: SILOXANE-BASED RESIN AND  
INTERLAYER INSULATING FILM FOR  
SEMICONDUCTOR DEVICE MADE  
USING THE SAME

Examiner: M. S. Zimmer

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**AMENDMENT AFTER FINAL ACTION (37 C.F.R. SECTION 1.116)**

MS AF  
Commissioner for Patents  
P.O. Box 1450  
Alexandria, VA 22313-1450

Sir:

**INTRODUCTORY COMMENTS**

In response to the Office Action dated May 9, 2005, finally rejecting claims 1-8 and 16, please amend the above-identified U.S. patent application as follows:

**Amendments to the Claims** are reflected in the listing of claims, which begins on page 2 of this paper.

**Remarks** begin on page 8 of this paper.